



DOCKET NO: 218781US0PCT

IN THE UNITED STATES PATENT & TRADEMARK OFFICE

IN RE APPLICATION OF

TAKEYOSHI SHIBASAKI, ET AL. : EXAMINER: NGUYEN, NGOC YEN M.
SERIAL NO: 10/049,902 :
FILED: JULY 8, 2002 : GROUP ART UNIT: 1754
FOR: AMORPHOUS FINE SILICA :
PARTICLE, ITS PRODUCTION PROCESS
AND APPLICATION

SUPPLEMENTAL AMENDMENT

COMMISSIONER FOR PATENTS
ALEXANDRIA, VIRGINIA 22313

SIR:

Further to the Amendment and Request for Continued Examination filed December 28, 2005, please amend the above-identified application as follows:

Amendments to the Claims begin on page 2 of this paper.

Discussion of Amendment and Remarks begin on page 6 of this paper.